



Process Optimization and Technology Development of Water Pollution Control

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Deadline for manuscript
submissions:

closed (25 April 2024)

Message from the Guest Editors

With the development of human society and the increase in the demand for water, water pollution is becoming increasingly serious. Types of wastewater mainly include domestic sewage and industrial wastewater (dyeing wastewater, coking wastewater, leather wastewater, pharmaceutical wastewater, etc.). The harmful chemical components in wastewater discharged into natural water bodies without treatment will cause devastating disasters to the water quality and aquatic organisms. The consumption of polluted water can also cause a variety of diseases. Therefore, wastewater must be treated so that it meets environmental discharge standards. The technology used to treat wastewater includes physical treatment, biological treatment, and chemical treatment. This Special Issue, entitled “Process Optimization and Technology Development of Water Pollution Control”, focuses on the latest novel developments in approaches and technology for the control of water pollution. This issue will publish new research papers, reviews, case reports, conference papers, etc.





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Message from the Editor-in-Chief

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